

Supplementary Material

Design of Iron (III) Phthalocyanine/Reduced Graphene Oxide Nanocomposites on Nickel Foam as Hybrid Supercapacitors

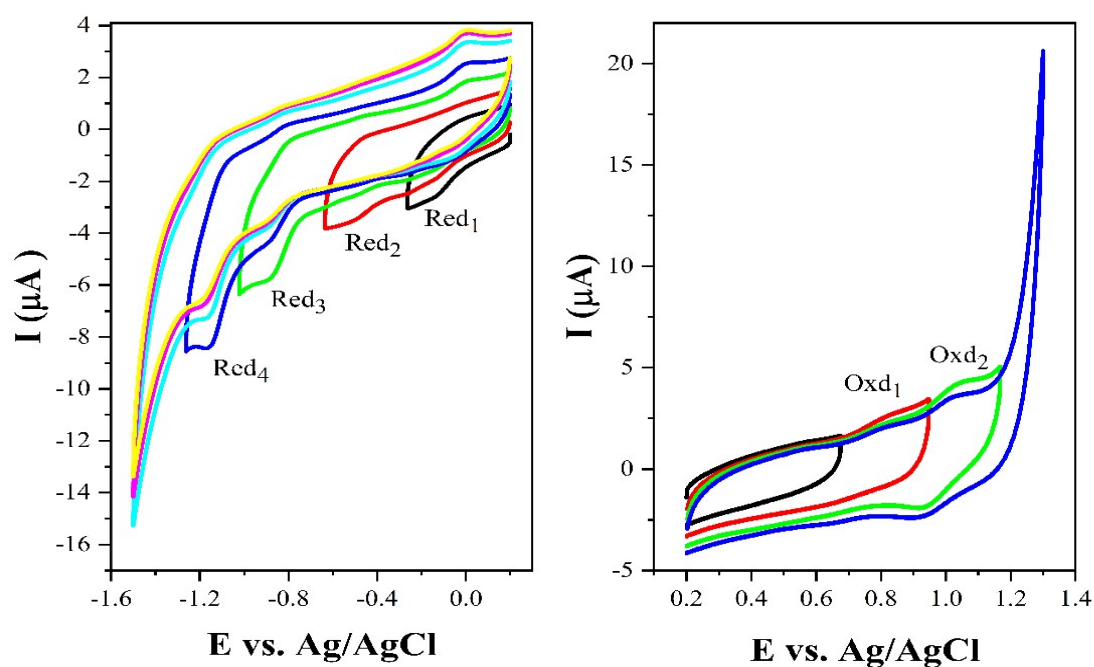
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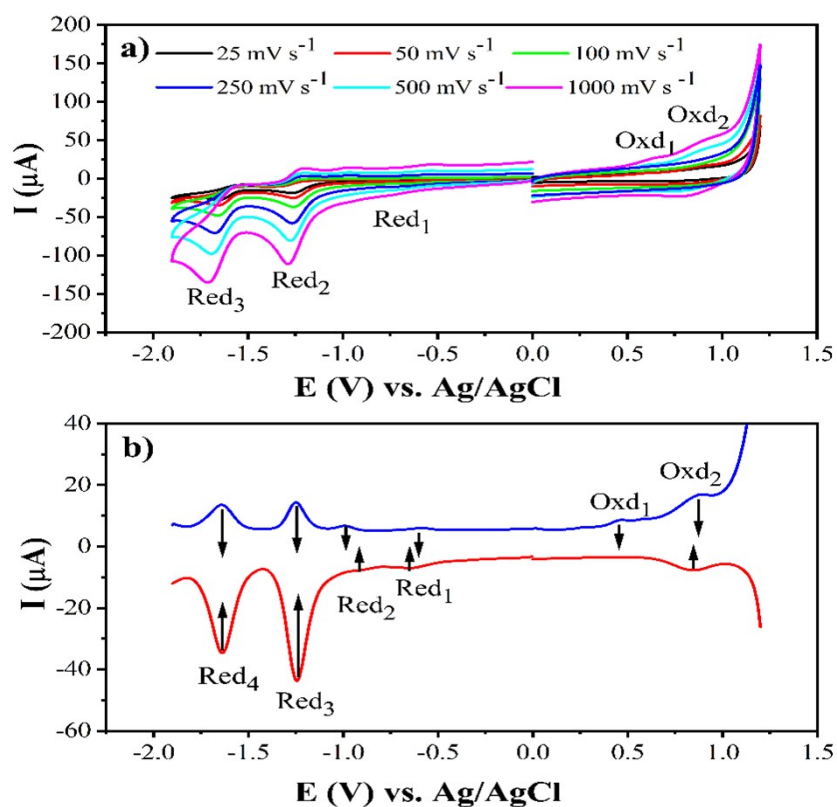
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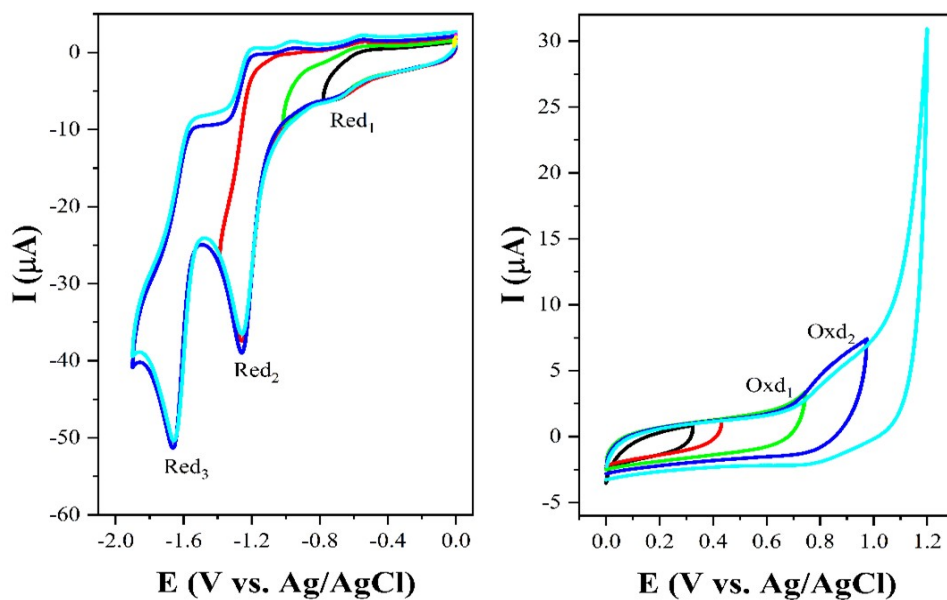
[†] These authors contributed equally to this work.



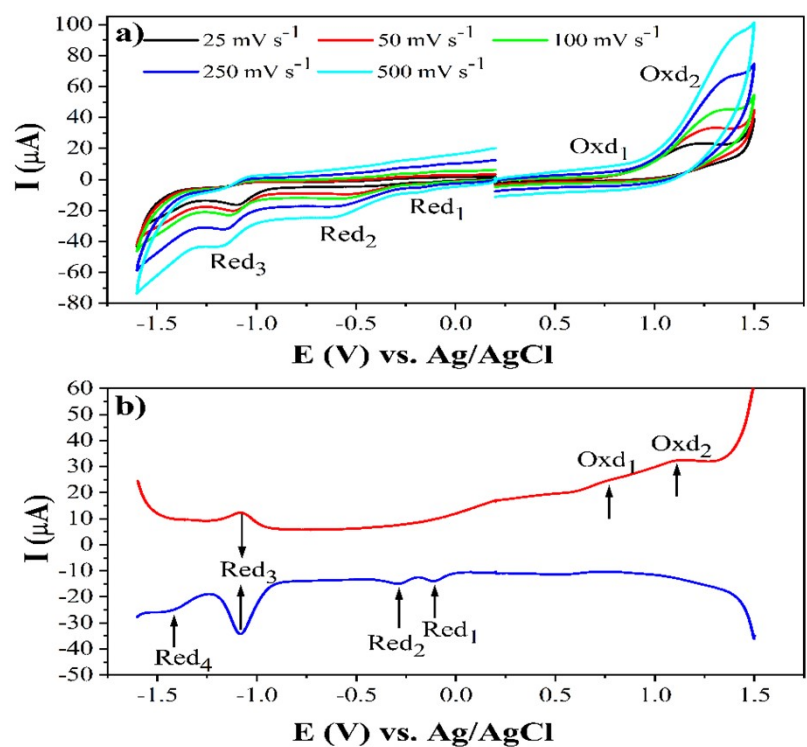
SM1 CVs of compound **1** recorded at 100 mVs⁻¹ scan rate with different vertex potentials within negative and positive potential ranges on a GCE working electrode in AN/TBAP electrolyte.



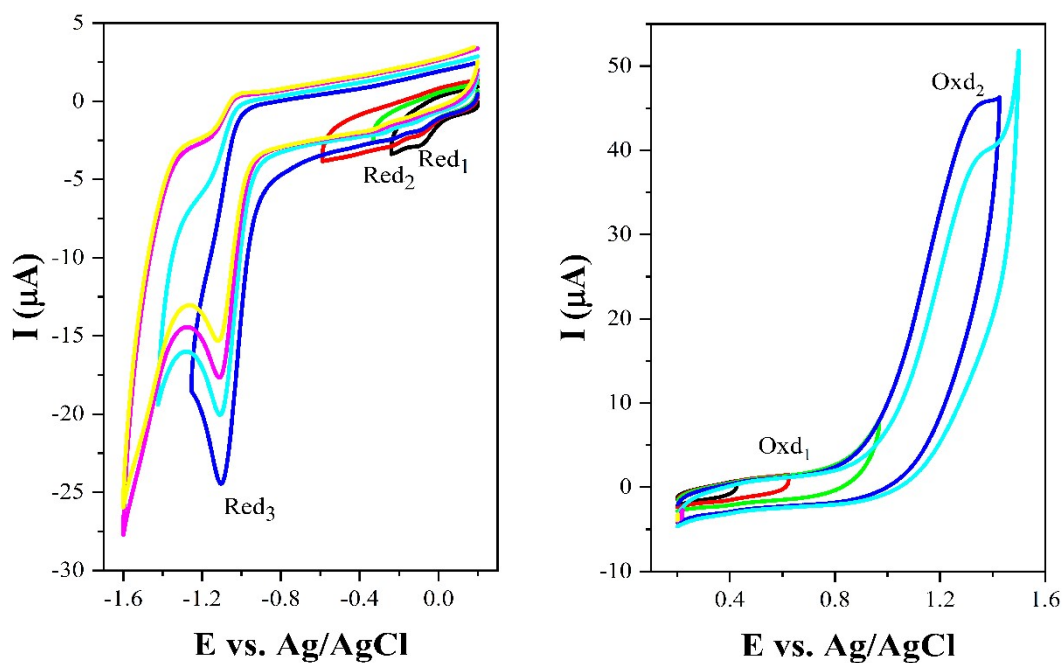
SM2 CVs and SWVs of compound **2** recorded at various scan rates on a GCE working electrode in AN/TBAP.



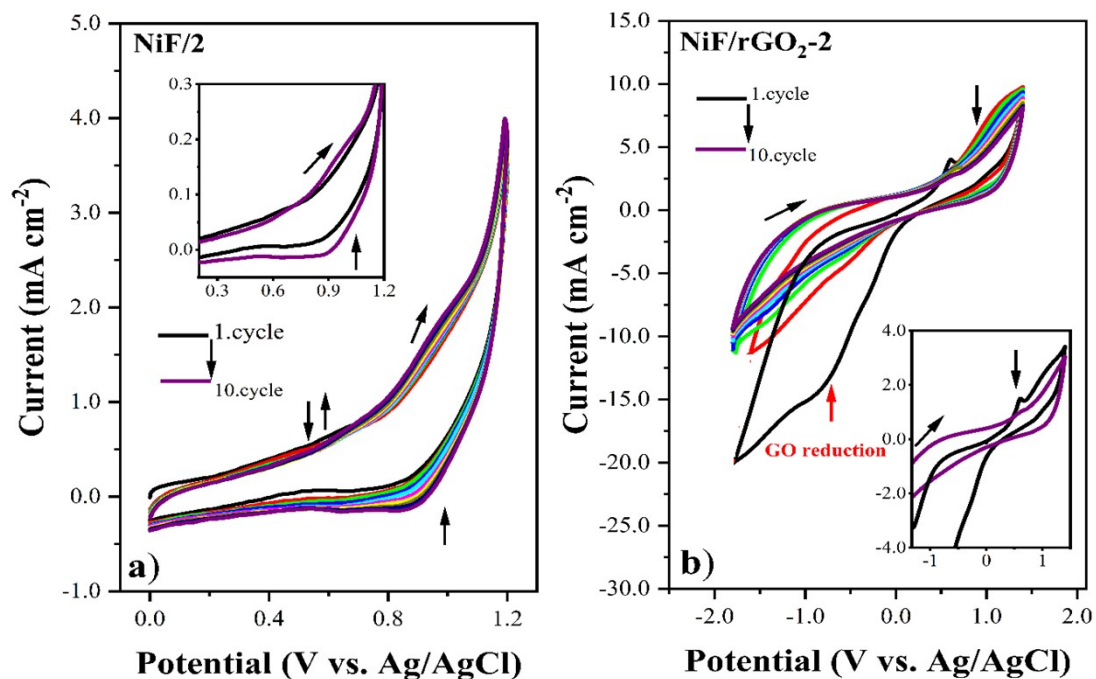
SM3 CVs of compound **2** recorded at 100 mV s^{-1} scan rate with different vertex potentials within negative and positive potential ranges on a GCE working electrode in AN/TBAP electrolyte.



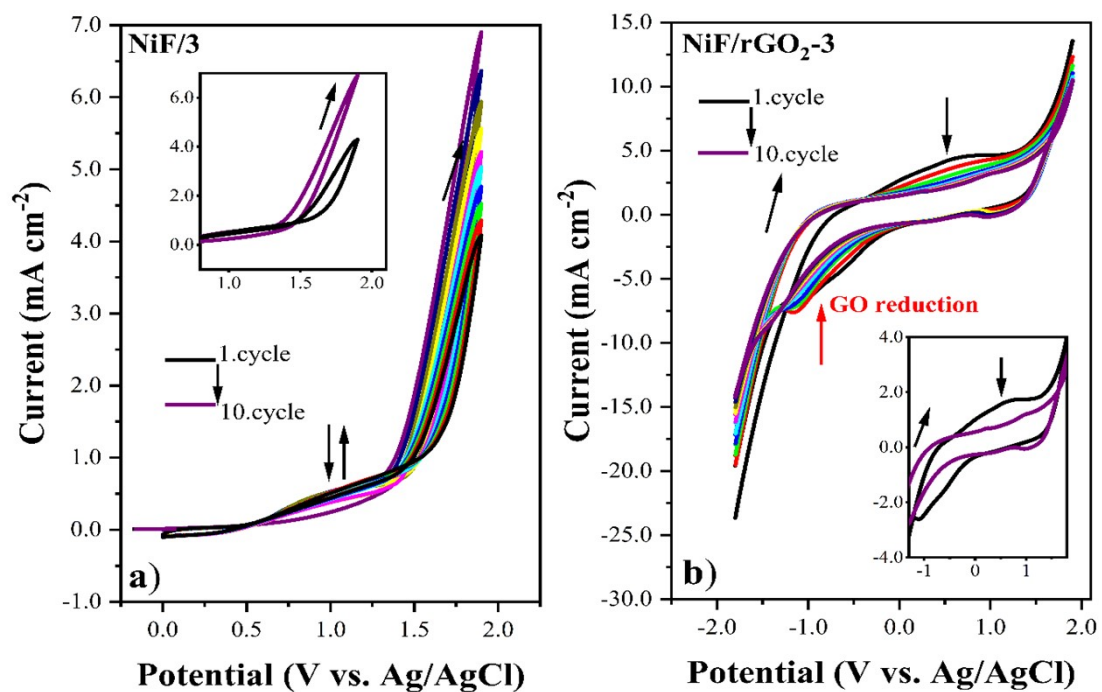
SM4 CVs and SWVs of compound **3** recorded at various scan rates on a GCE working electrode in AN/TBAP.



SM5 CVs of compound **3** recorded at 100 mV s^{-1} scan rate with different vertex potentials within negative and positive potential ranges on a GCE working electrode in AN/TBAP electrolyte.



SM6 rCVs scans of a) NiF/2 and b) NiF/rGO₂-2 electrodes a scan rate of 100 mV s⁻¹ in the AN/TBAP medium.



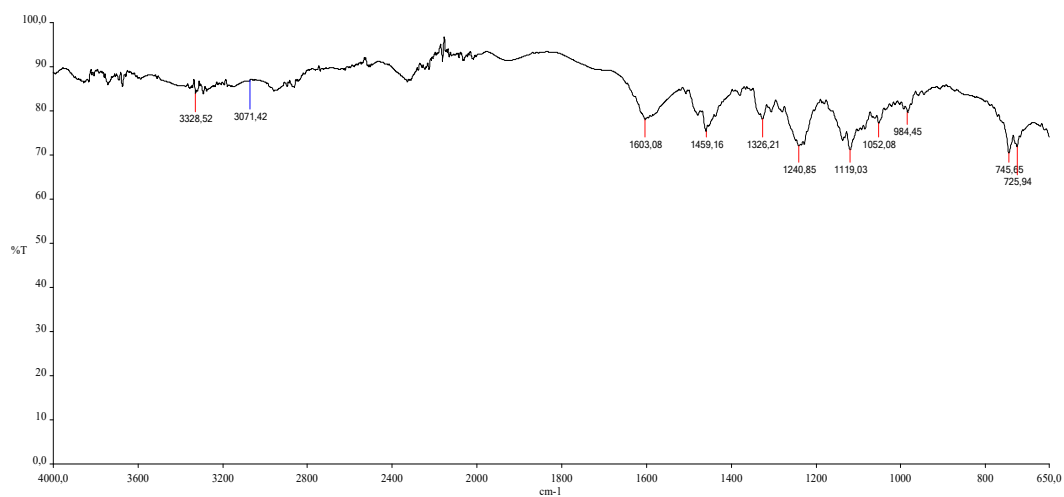
SM7 rCVs scans of a) NiF/3 and b) NiF/rGO₂-3 electrodes a scan rate of 100 mV s⁻¹ in the AN/TBAP medium.

Table SM1. The Rs values of the electrodes.

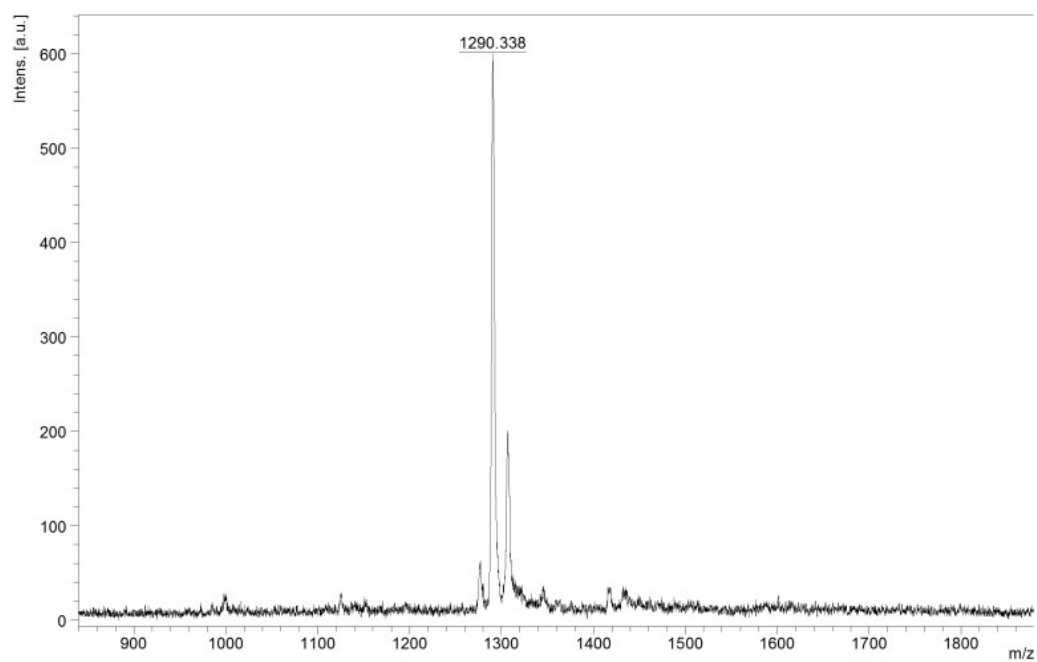
Electrode	Rs (Ω)
NiF/1	1.64
NiF/rGO ₂ -1	1.00
NiF/2	1.82
NiF/rGO ₂ -2	1.21
NiF/3	2.02
NiF/rGO ₂ -3	1.53

Table SM2. Supercapacitive performance of previously reported metallophthalocyanine structures: a comparative summary.

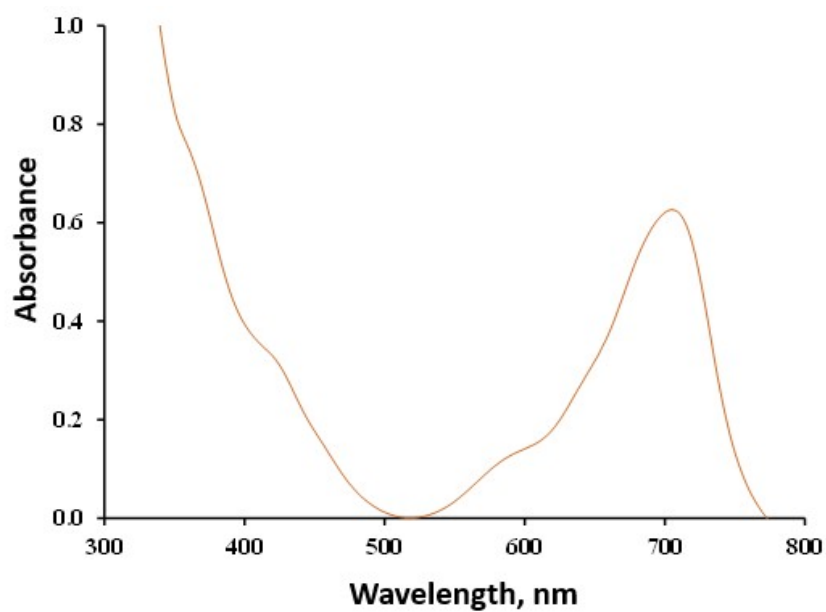
Electrode	Method	Specific capacitance	Electrolyte	Retention	Ref.
PdTAHAPc	Drop casting	245 F g ⁻¹ (0.2 A g ⁻¹) 221 g ⁻¹ (1 A g ⁻¹)	1 M H ₂ SO ₄	100% (5000 cycle)	[1]
CoPc-COF/CS	Freeze-drying	556 F g ⁻¹ (1 A g ⁻¹)	6 M KOH	-	[2]
CoNCCs	Microwave-assisted	213.4 F g ⁻¹ (0.5 A g ⁻¹)	1 M H ₂ SO ₄	85.3% (1750 cycle)	[3]
SWCNTs/Pc (SPCM -10)	Drop casting	228 F g ⁻¹ (0.5 A g ⁻¹)	6 M KOH	93% (2000 cycle)	[4]
BTCuPc	Drop casting	265 F g ⁻¹ (5 mV s ⁻¹)	3 M KCl	-	[5]
FePcGO ₂	Coating with binder	514 F g ⁻¹ (1 A g ⁻¹)	6 M KOH	-	
Co(NO ₂) ₄ Pc-rGO 1/6	-	150.22 F g ⁻¹ (4 A g ⁻¹)		116.6% (5000 cycle)	[6]
NiMe ₂ Pc:CNT-COOH (6:10)	Doctor blade	33 0.5 F g ⁻¹ (0.25 A g ⁻¹)	1 M H ₂ SO ₄	-	[7]
FePc@MWCNTs	Knife coating	65.3 F g ⁻¹ (0.25 A g ⁻¹)	1 M H ₂ SO ₄	-	[8]
CoTPCAPc/MWCNT/GC	Drop casting	475.65 F g ⁻¹ (50 mV s ⁻¹)	1 M H ₂ SO ₄	89.1% (1000 cycle)	[9]
NiF/rGO ₂ -1	One-step electrodeposition	590.4 F g ⁻¹ (0.5 A g ⁻¹) 494.8 F g ⁻¹ (1 A g ⁻¹)	2 M KOH	85.2% (5000 cycle)	This work



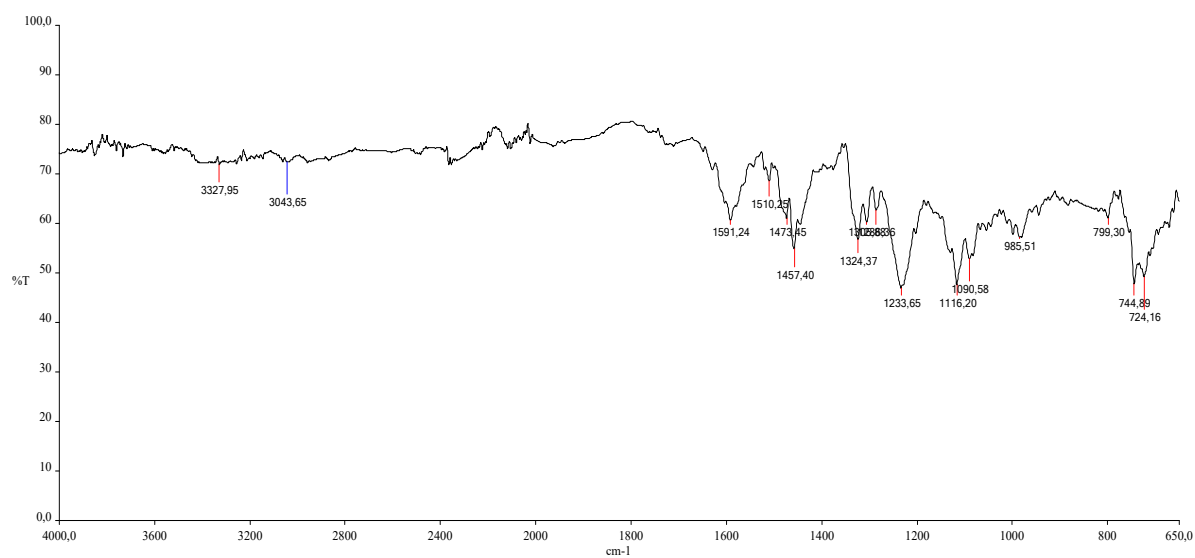
SM8 FT-IR spectrum of compound **1**.



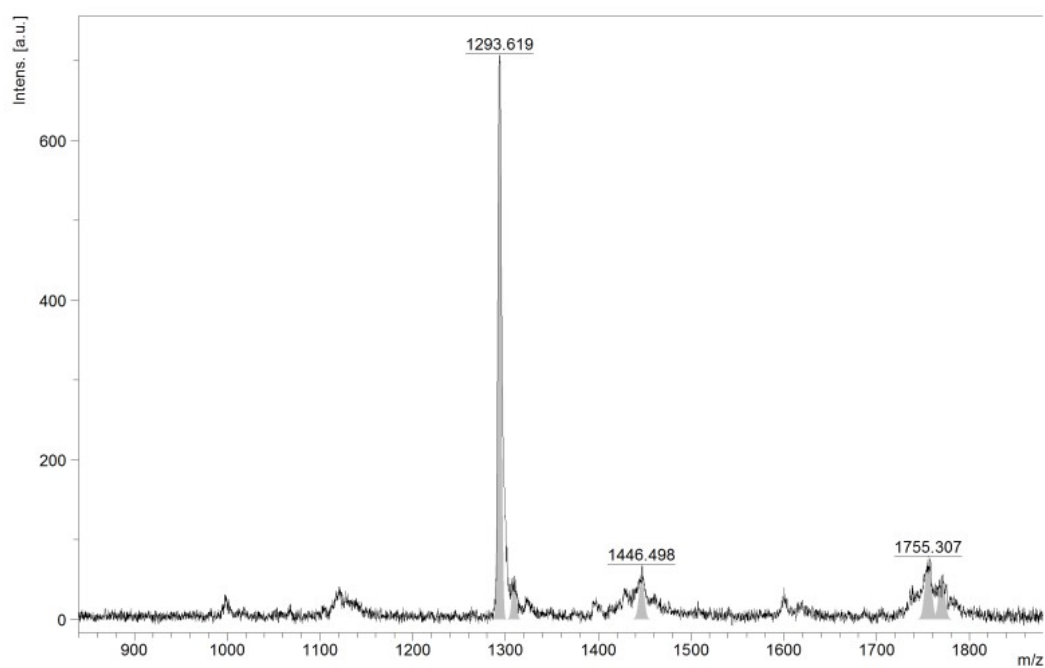
SM9 Mass Spectrum of compound **1**.



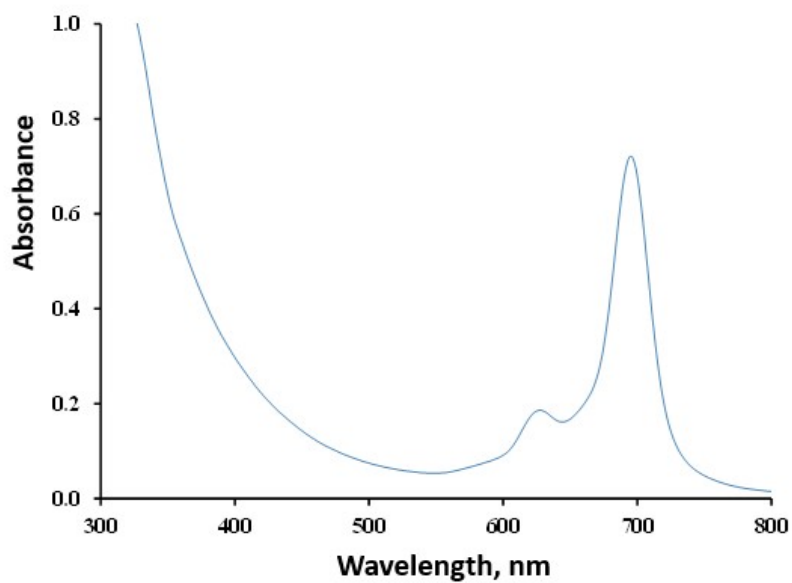
SM10 UV-vis spectrum of compound **1**.



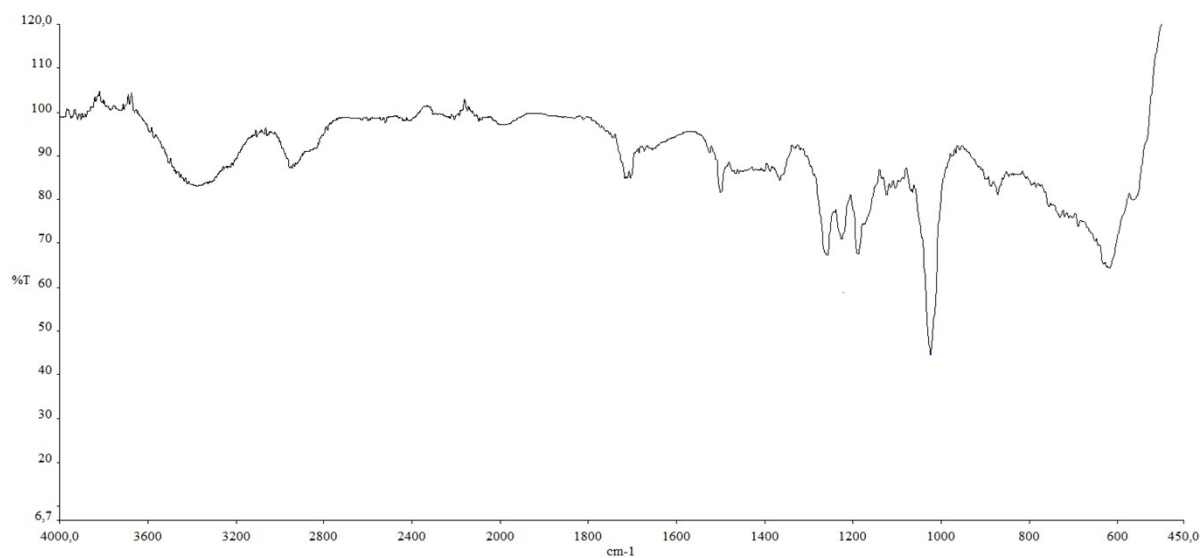
SM11 FT-IR spectrum of compound **2**.



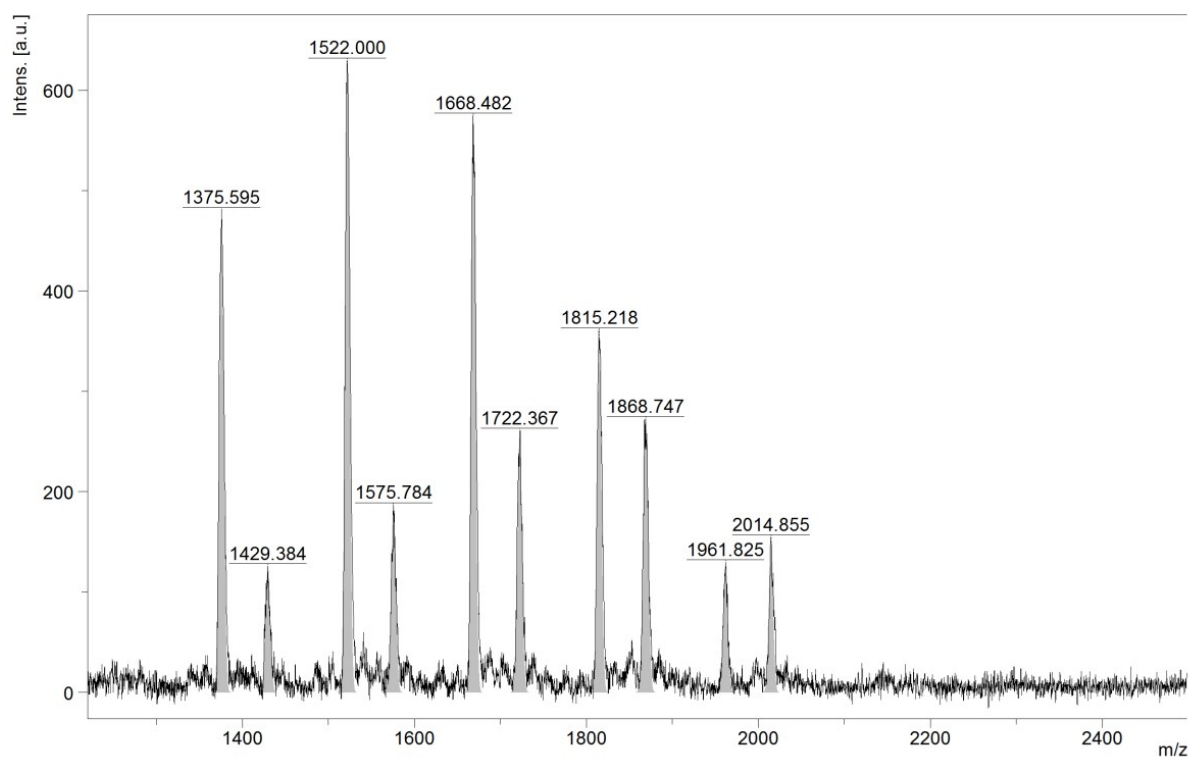
SM12 Mass Spectrum of compound **2**.



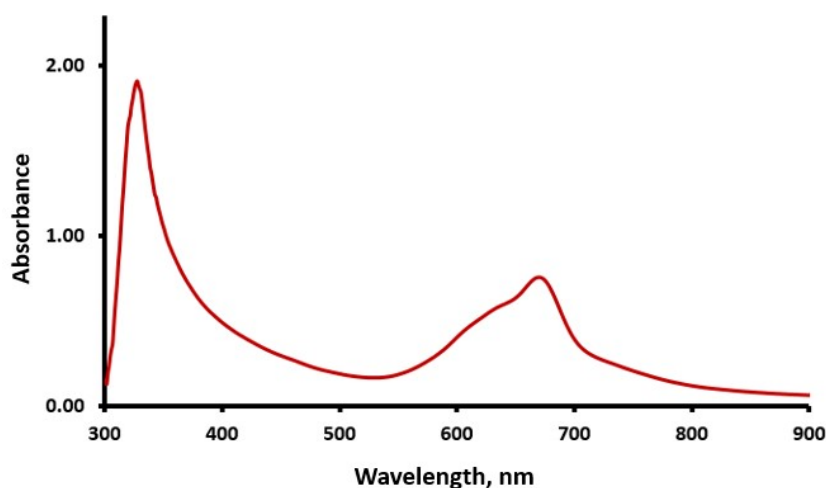
SM13 UV-vis spectrum of compound **2**.



SM14 FT-IR spectrum of compound **3**.



SM15 Mass Spectrum of compound **3**.



SM16 UV-vis spectrum of compound **3**.

References

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